FINAL REFLECTIVE SURFACE CONDITION WITH AVAILABLE REFLECTIVITY ENHANCEMENT COATINGS DEFINED AS FOLLOWS: ADD DESIGNATED SUFFIX TO PN:

- RH ELECTRO-DEPOSITED BRIGHT RHODIUM
- AD VACUUM DEPOSITED ALUMINUM WITH SiO₂ (QUARTZ)
- AF VACUUM DEPOSITED ALUMINUM WITH MgF₂ (MAGNESIUM FLUORIDE)
- OCD DICHROIC COLD COATING - SPECIFY WAVELENGTH REGION
- SP OTHER SPECIAL COATINGS AS SPECIFIED

-2 REFLECTOR WITHOUT FORMED FLANGED.

VERTICAL MOUNTING IS PREFERRED.

PLAN OF CLEAR APERTURE (CA) NOT RECOMMENDED FOR THIS PURPOSE.

VERTEX THICKNESS T MAY VARY ± T/4 WITHIN .25 OF EDGES.

REVIEWERS:

REVISED DRAWING

DRAWING

CHECKED

REVISIONS

DATE REF. DESCRIPTION OVL. APPRVD.

4 02-05-98 KEN S

3 02-06-98 KEN S

2 06-26-90 GPA /

1 04-14-93 GPA /

SCALE 1/1

E397-9.PDF SHEET 1 OF 1

APPENDICIES

NOTES

PARTS LIST

SPEC CONTROL DWG

REFLECTOR, ELLIPTICAL

15.65°/397 mm (F1-F2)